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Ayman Karar  
*Edith Cowan University*

Narottam Das  
*Edith Cowan University*

Chee Leong Tan  

Kamal Alameh  
*Edith Cowan University*

Yong Tak Lee

*See next page for additional authors*

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Authors
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Ayman Karar,1,a) Narottam Das,1,b) Chee Leong Tan,2 Kamal Alameh,1,3,c) Yong Tak Lee,2,3,4 and Fouad Karouta5

1Electron Science Research Institute, Edith Cowan University, Joondalup, WA, Australia
2School of Photonics Science, Gwangju Institute of Science and Technology (GIST), Gwangju, South Korea
3Department of Information and Communications, GIST, Gwangju, South Korea
4Department of Nanobio Materials and Electronics, GIST, Gwangju, South Korea
5ANFF, Research School of Physics & Engineering, Australian National University, Canberra, Australia

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We report the experimental characterization of high-responsivity plasmonics-based GaAs metal-semiconductor-metal photodetector (MSM-PD) employing metal nano-gratings. Both the geometry and light absorption near the designed wavelength are theoretically and experimentally investigated. The measured photocurrent enhancement is 4-times in comparison with a conventional single-slit MSM-PD. We observe reduction in the responsivity as the bias voltage increases and the input light polarization varies. Our experimental results demonstrate the feasibility of developing a high-responsivity, low bias-voltage high-speed MSM-PD. © 2011 American Institute of Physics. [doi:10.1063/1.3625937]

Metal-semiconductor-metal photodetectors (MSM-PDs) are very attractive devices due to their potential applications in optical fiber communication systems, high-speed chip-to-chip interconnects, and high-speed sampling.1,2 Due to their lateral geometry, MSM-PDs have much smaller capacitance per unit area in comparison to standard p-i-n photodiode with same active area. The surface reflectivity and the shadowing due to the metal fingers prevent an ideal MSM-PD from achieving external quantum efficiency greater than 50% for equal electrode width and spacing. On the other hand, the smaller finger width, the less detector capacitance, and the shorter external response time.3 By decreasing the spacing between the electrode fingers down to the optical diffraction limit, the response times could be in the range of a few tens of picoseconds.4 However, this down sizing of the electrode spacing decreases the active area, thus resulting in photodetector sensitivity degradation.

Since the extraordinary optical transmission (EOT) phenomenon, which was reported by Ebbesen et al.,5 many efforts have been devoted to exploring the EOT through metallic gratings with various sub-wavelength structures, such as periodic slit arrays, hole arrays, and corrugated metal films for different wavelength regions.6–8 It has also been established that the transmission of light through a hole or sub-wavelength slit in a metal film can be enhanced by micro-structuring the top or bottom surfaces of the film with gratings. These gratings couple the incident light with the surface plasmon polaritons (SPPs), which are guided into the sub-wavelength slit.11

Several different implementations of SPP-enhanced MSM-PDs have been reported confirming that the confinement of light in sub-wavelength metal–semiconductor nano-gratings can be achieved by Fabry–Pérot resonances involving vertical transverse magnetic (TM) and electric guided waves, resulting in increasing the quantum efficiency.12,13 Lee et al.,14 have reported a plasmonic metal photonic crystal (MPC) integrated on a quantum dot infrared photodetector demonstrating more than 2-times enhancement in detectivity. Recently, we reported a semi-analytical model of light absorption around 830 nm for MSM-PDs with plasmonic nano-gratings using the finite difference time domain (FDTD) numerical method.15 In that report, we showed that the transmission enhancement strongly depends on several parameters of the device structure, such as, the shape, height, and grating period, as well as, the sub-wavelength aperture width.

In this letter, we report on the development of a plasmonics-based GaAs MSM-PD structure fabricated using focused ion beam (FIB) milling and demonstrate responsivity enhancement of 4-times in comparison with conventional single-slit MSM-PDs, attributed to the SPP-assisted extraordinary optical transmission through the metal nano-gratings.

Figure 1 illustrates the schematic diagram of the plasmonics-based MSM-PD structure. The sub-wavelength slit (\(\lambda_W\)) is etched between the metal nano-gratings of a grating period (\(\Lambda\)). The incident electromagnetic field is assumed a TM polarized wave with magnetic field oscillating in the direction parallel to the nano-grating grooves. The metallic sub-wavelength aperture supports a propagating TM mode with the EOT. Consequently, with an appropriate choice of its width, the sub-wavelength aperture forms a Fabry–Pérot resonator; therefore, the light transmission through the sub-wavelength aperture is resonantly enhanced. On the other hand, the nano-gratings enhance the light transmission through the sub-wavelength aperture region by converting the incident electromagnetic (EM) waves into SPPs propagating on the metallic surface, which can be funnelled into the sub-wavelength aperture. With an accurate choice of geometric parameters of the structure, these two mechanisms can occur at the same time, resulting in an increase in the
electron-hole pair generation rate and leading to a substantial increase in the overall photodetector responsivity.

The metal nano-gratings etched on both sides of the slit allow, through momentum difference, collective resonant coupling between the incident light and oscillating electrons. The metal nano-grating period \( \Lambda \) is obtained using the following dispersion relation

\[
k_{||} = k_0 \sin \theta = \frac{2n \pi}{\Lambda} = k_0 \sqrt{\frac{\varepsilon_m \varepsilon_d}{\varepsilon_m + \varepsilon_d}} = k_p,
\]

where, \( k_{||} \), \( k_p \), and \( k_0 \) represent the parallel component of the incident light wave vector with respect to the device surface, the SPPs and free space wave vectors, respectively, \( n \) is an integer number and \( \theta \) is the incident angle of the light. The complex dielectric permittivity of the metal is \( \varepsilon_m = \varepsilon_m' + i \varepsilon_m'' \) and that of the air is \( \varepsilon_d \). Using this relation, a period of \( \Lambda = 815 \) nm for the Au/air interface results in an absorption spectrum of absorption edge around 830 nm for normal light incidence.

A thorough analysis of the plasmonics-based MSM-PD structure was performed using the two-dimensional FDTD method. A plane Gaussian-modulated continuous wave with TM polarization was used as an excitation source, as reported in Ref. 15. By simulating the electric flux transmitted into the structure was performed using the two-dimensional FDTD method. A plane Gaussian-modulated continuous wave with TM polarization was used as an excitation source, as reported in Ref. 15. By simulating the electric flux transmitted into the device surface, the SPPs and free space wave vectors, respectively, \( n \) is an integer number and \( \theta \) is the incident angle of the light. The complex dielectric permittivity of the metal is \( \varepsilon_m = \varepsilon_m' + i \varepsilon_m'' \) and that of the air is \( \varepsilon_d \). Using this relation, a period of \( \Lambda = 815 \) nm for the Au/air interface results in an absorption spectrum of absorption edge around 830 nm for normal light incidence.

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that, since the plasmonics-based MSM-PD is a polarization-sensitive device, a polarization controller was used to ensure that the device was always illuminated by TM polarized light and maximum enhancement was attained for all the measurements.

As reported by Ren et al., in addition to the significant transmission enhancement, both high speed and low dark current would result, since; in this case, the response speed of the MSM-PD is primarily limited by the transit time of the optically generated carriers and the RC-time constant of the interdigitated PD structure. Note that etching multiple nano-size metal fingers results in a higher light power being absorbed in the semiconductor region. However, this results in a higher number of alternating thinner metal fingers that increase both the total capacitance and the total resistance of the MSM-PD, thus leading to a much lower speed as reported by Burm et al., and Yuang and Chyi. For a slit width in the order of 200 nm, at low bias the semiconductor region of the MSM-PD is completely depleted and the electric field through the slit becomes high enough that the carriers drift at near saturation velocities. Under this condition, the transit time is simply determined by \( \tau_{dr} = \frac{t}{v} \) as shown in Ref. 18, where \( t \) is the gap width between the fingers, \( v \) is carriers drift mean velocity, and \( \chi \) is carrier drift distance corrective coefficient. Given the mean velocity of \( 6.7 \times 10^6 \text{ cm/s} \) and the carrier drift distance corrective coefficient \( \chi = 1.3 \) for the electron and hole in GaAs, the transit time of carrier and the frequency response bandwidth \( (f_{tr}) \) are estimated to be 1.9 ps and 83 GHz, respectively.

In conclusion, we have designed and fabricated a plasmonics-based MSM-PD device employing metal nano-gratings and subwavelength slit. FDTD method has been used to optimize the various device parameters, and a dual beam FIB/SEM has been employed for the fabrication of the metal nano-gratings and slit of the MSM-PD. We have experimentally demonstrated the principle of plasmonics-based MSM-PDs and attained a measured photodetector responsivity that is 4-times better than that of conventional single-slit MSM-PDs.

FIG. 3. An SEM image of the fabricated plasmonics-based MSM-PD structure. The inset shows a high magnification image of the sub-wavelength slit with linear nano-gratings at both sides.

FIG. 4. (Color online) (a) Measured I-V characteristics comparing two GaAs MSM-PDs WGS and WOGs for different illumination power levels. (b) Photocurrent enhancement factor \( \left( \frac{I_{WGS}}{I_{WOG}} \right) \) versus input voltage for an input laser power of 3 mW.